

File View Edit Tools Window Help

- ☐ Drafts
- ☒ Pending
- ☒ Active
- ☒ L1: (442) concentric near2 anode
- ☒ L2: (574049) semiconductor or wafer
- ☒ L3: (89) 11 and 12
- ☒ L4: (1812) concentric same anode
- ☒ L5: (421) 14 and 12
- ☒ L6: (18138) (204/198-297.16).CCLS.
- ☒ L7: (16283) (205/50-333).CCLS.
- ☒ L8: (92) 15 and (16 or L7)
- ☒ L9: (49) 18 not 13
- ☒ L10: (102246) ("438").CLAS.
- ☒ L11: (28) 12 and 14 and 110
- ☒ L12: (19) 111 not (13 or 19)
- ☒ L13: (244) (204/dig.7).CCLS.
- ☒ L14: (257) (205/96-97).CCLS.
- ☒ L15: (198) 114 not 113
- ☒ L16: (958) anode near2 (segment or segmented)
- ☒ L17: (130) 116 and (16 or 17)
- ☒ Failed
- ☒ Saved
- ☒ Favorites
- ☒ Tagged (0)
- ☒ UDC
- ☒ Queue
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<div><div><div><div><div><div></div><div>BRS form</div></div><div><div>USIP form</div><div>Image</div><div>Text</div><div>HTML</div></div></div></div></div></div>													
Document ID	Issue Date	Pages	Title	Current OR	Current XRef	Inventor	U	S	C	P	1	3	pt.
1 US 20050199502 A1	20050915	14	Method for electroplating on resistive substrates	205/102	205/291	Andricacos, Panayotis et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
2 US 20050189229 A1	20050901	6	Method and apparatus for electroplating a semiconductor wafer	205/157		Powers, James	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
3 US 20050173250 A1	20050811	11	Device and method for monitoring an electrolytic process	205/83		Thies, Andreas et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
4 US 20050166706 A1	20050804	16	Thermal and electrochemical process for metal production	75/10.23	205/103; 205/557;	Withers, James C. et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
5 US 20050161336 A1	20050728	14	Electroplating apparatus with segmented anode array	205/123	204/198; 204/224R	Woodruff, Daniel J. et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
6 US 20050161320 A1	20050728	13	Electroplating apparatus with segmented anode array	204/198	204/224R	Woodruff, Daniel J. et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
7 US 20050145499 A1	20050707	23	Plating of a thin metal seed layer	205/103		Kovarsky, Nicolay Y. et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
8 US 20050109612 A1	20050526	13	Electroplating apparatus with segmented anode array	204/242	204/267	Woodruff, Daniel J. et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
9 US 20050109611 A1	20050526	13	Electroplating apparatus with segmented anode array	204/242	204/267	Woodruff, Daniel J. et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
10 US 20050006245 A1	20050113	10	Multiple-step electrodeposition process for direct copper plating on barrier	205/291	205/123; 257/E21.175;	Sun, Zhi-wen et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
11 US 20040262152 A1	20041230	27	Electrochemical system for analyzing performance and properties of	204/230.2	204/242	Landau, Uziel	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
12 US 20040245096 A1	20041209	13	Dimensionally stable anode for the electrowinning of aluminum	204/290.01		Julsrud, Stein et al.	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
13							<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>

Ready

NUM

EAST - [Untitled1:]
☐ File View Edit Tools Window Help

☒ Drafts
☒ Pending
☒ Active
☒ L1: (71532) ("204") or ("205"). CLAS.
☒ L2: (442) anode near2 concentric
☒ L3: (176) 11 and 12
☒ L4: (252634) spacer
☒ L5: (8) 12 same 14
☒ L6: (3) 15 and 11
☒ L7: (1264) leader.xa.
☒ L8: (6) 17 and 12
☒ L9: (199817) concentric
☒ L10: (75) 17 and 19
☒ L11: (9) Backward citation search 1
☒ L12: (848604) insulate or insulates or insulated or insulating o
☒ L13: (101) 12 same 112
☒ L14: (28) 113 and 11
☒ Failed
☒ Saved
☒ Favorites
☒ Tagged (0)
☒ UDC
☒ Queue
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